

# OPTICAL AND QUANTUM EFFICIENCY ANALYSIS OF (Ag,Cu)(In,Ga)Se<sub>2</sub> ABSORBER LAYERS

Jonathan Boyle<sup>1,2</sup>, Gregory Hanket<sup>1</sup>, and William Shafarman<sup>1,2</sup>

1. Institute of Energy Conversion, University of Delaware, Newark, DE 19716

2. Department of Materials Science and Engineering, University of Delaware, Newark, DE 19716

## ABSTRACT

(Ag,Cu)(In,Ga)Se<sub>2</sub> thin films have been deposited by elemental co-evaporation over a wide range of compositions and their optical properties characterized by transmission and reflection measurements and by relative shift analysis of quantum efficiency device measurements. The optical bandgaps were determined by performing linear fits of  $(\alpha h\nu)^2$  vs.  $h\nu$ , and the quantum efficiency bandgaps were determined by relative shift analysis of device curves with fixed Ga/(In+Ga) composition, but varying Ag/(Cu+Ag) composition. The determined experimental optical bandgap ranges of the Ga/(In+Ga) = 0.31, 0.52, and 0.82 groups, with Ag/(Cu+Ag) ranging from 0 to 1, were 1.19-1.45 eV, 1.32-1.56 eV, and 1.52-1.76 eV, respectively. The optical bowing parameter of the different Ga/(In+Ga) groups was also determined.

## INTRODUCTION

One approach to increase the efficiency of Cu(In,Ga)Se<sub>2</sub>-based modules is to increase  $V_{OC}$  by increasing the bandgap ( $E_g$ ) [1]. Increasing  $V_{OC}$  will also lead to a reduction in resistive power losses [2]. An increase in  $V_{OC}$  with  $E_g$  has been well-established by alloying with Al, Ga, and/or S into the CuInSe<sub>2</sub> alloy, but in all cases, with  $E_g > 1.3$  eV, the efficiency decreases and  $V_{OC}$  saturates at 800 – 850 mV [2]. The inclusion of Ag into the Cu(In,Ga)Se<sub>2</sub> alloy to form (Ag,Cu)(In,Ga)Se<sub>2</sub> is being investigated as a means to increase  $V_{OC}$  and improve the performance of wide bandgap devices by lowering the melting point temperature of the material, potentially leading to lower defect densities [3]. Improved wide bandgap solar cells may also enable their application as a top cell in a tandem cell device.

Previous studies by Avon, et al. [4] of ampoule-synthesized-ingot (Ag,Cu)(In,Ga)Se<sub>2</sub> have determined the optical bandgap and optical bowing parameter for limited compositional ranges. This work expands upon this in determining the bandgaps and the bowing parameters for a wider range of compositions of (Ag,Cu)(In,Ga)Se<sub>2</sub> thin films. Supplementary work by Avon, et al. [5] on the same (Ag,Cu)(In,Ga)Se<sub>2</sub> ampoule-synthesized-ingot-based samples also reported a chalcopyrite-chalcopyrite immiscibility gap for certain bulk compositions. X-ray diffraction (XRD) studies of the thin films studied here showed a single phase throughout the alloy compositional

system. Details on the XRD studies along with device results and analysis are reported at this conference [6].

In this work, we characterized the optical properties of (Ag,Cu)(In,Ga)Se<sub>2</sub> thin films deposited by elemental co-evaporation with systematic changes in the relative Ag/(Cu+Ag) and Ga/(In+Ga) compositions. Changes in bandgap determined by optical transmission and reflection measurements on thin films on bare glass and from quantum efficiency (QE) curves of devices are compared.

## EXPERIMENTAL

The (Ag,Cu)(In,Ga)Se<sub>2</sub> samples were deposited using elemental co-evaporation from Knudsen sources onto Mo-coated soda lime glass (SLG) and bare soda lime glass substrates. Elemental fluxes were kept constant for a 60 minute deposition, with the substrate temperature held at 550°C. The resulting films were 2  $\mu$ m thick. The samples had a range of compositions spanning  $w = Ag/(Cu+Ag)$  from 0 to 1, and  $x = Ga/(In+Ga)$  from 0.31 to 1. Target  $w/x = (Cu+Ag)/(In+Ga)$  compositions were within the range of 0.8 to 0.9. Compositions were determined by energy dispersive x-ray spectroscopy (EDS). A typical quantum efficiency absolute error for composition determined from the EDS measurements for a Cu(In,Ga)Se<sub>2</sub> control sample gave  $x = 0.31 \pm 0.04$  ( $w = 0$ ), which gives  $\pm 0.02$  eV for the bandgap analysis.

The samples on bare soda lime glass substrates were analyzed using a Perkin-Elmer UV/Vis/NIR spectrophotometer equipped with an integrating sphere. Total transmission (T) and reflection (R) data were obtained from 500-2500 nm at 1 nm intervals. The T and R data was smoothed with a 5 point box smooth. Mo films were deposited by dc sputtering and the Mo-coated soda lime glass substrate samples were fabricated into solar cell devices with the structure: SLG/Mo/(Ag,Cu)(In,Ga)Se<sub>2</sub>/CdS/ZnO/ITO/Ni:Al grids. The CdS was deposited by chemical bath deposition, the ZnO and ITO were deposited by RF sputtering, and the Ni:Al grids were electron-beam evaporated. Quantum efficiency results were obtained under white light bias and as a function of voltage.

## RESULTS

The normalized transmission [T/(1-R)] curves of a set of films with  $x = 0.31 \pm 0.02$  and  $w$  spanning 0 to 1 are shown in Figure 1. The increasing bandgap with

increasing  $w$  is seen in the shift of the transmission curves to lower wavelengths or higher energies.

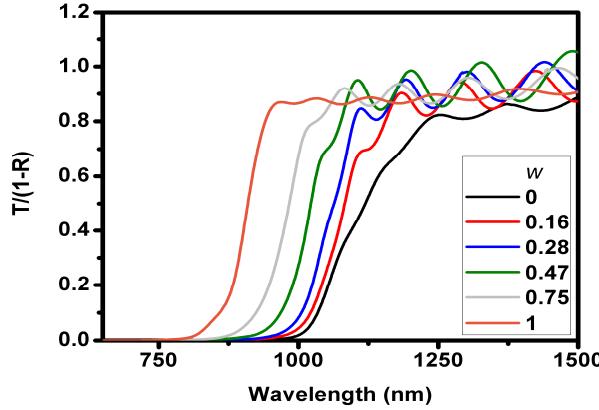


Figure 1. Normalized transmission  $T/(1-R)$  for films with  $x = 0.31$  and varying  $w$ .

It can also be seen from the transmission spectra in the sub-bandgap energy range, that the control  $\text{Cu}(\text{In},\text{Ga})\text{Se}_2$  ( $w = 0$ ) sample has greater sub-band gap absorption (lower transmission) than the  $(\text{Ag},\text{Cu})(\text{In},\text{Ga})\text{Se}_2$  samples [7]. This suggests that the  $(\text{Ag},\text{Cu})(\text{In},\text{Ga})\text{Se}_2$  films may have a lower density of defects than the control  $\text{Cu}(\text{In},\text{Ga})\text{Se}_2$  ( $w = 0$ ) sample [7]. Transient photospectroscopy measurements on similar samples showed sharper optical bandtails which were similarly attributed to higher quality material [8]. The high transmission in the  $(\text{Ag},\text{Cu})(\text{In},\text{Ga})\text{Se}_2$  films would be beneficial for application to the top cell in a tandem structure.

The optical bandgap was determined from the transmission and reflection data using a standard analytical procedure [9]. The absorption coefficient ( $\alpha$ ) was determined using Equation (1):[10]

$$\alpha(\lambda, R, T) = \left( \frac{1}{d} \right) \ln \left[ \frac{(1-R)^2}{T} \right] \quad (1)$$

where  $d$  is the sample thickness in cm and  $\lambda$  is the incident wavelength. The bandgap was determined by plotting  $(\alpha h\nu)^2$  vs.  $h\nu$  and performing a linear fit of the data. This assumes that the fundamental optical transition is due to a direct allowed transition in all cases [9]. Sample curves are shown in Figure 2 for two  $x = 0.3$  samples ( $w = 0$  and 1).

As can be seen in Figure 2, the samples have a linear region, which is fit to determine  $E_g$ . At higher energies, the increased slope of the  $\text{Cu}(\text{In},\text{Ga})\text{Se}_2$  control is attributed to the non-degenerate valence band splitting of chalcopyrite materials [9]. It is not known at this time whether the differences in curve shape and slope of the two samples can be attributed to changes in band splitting, due to crystal-field and spin-orbit splitting, a reduction in defects, a combination of both, or other effects.

The results of the linear fits of Figure 2 are presented in Table I, and the values of  $E_g$  similarly determined for  $x = 0.31$ , 0.52, and 0.82 are listed in Table II. With wider bandgap films that have greater  $w$ , the linear region becomes smaller and determination of  $E_g$  becomes less accurate as seen by the statistical absolute error ( $\Delta E_g$ ).

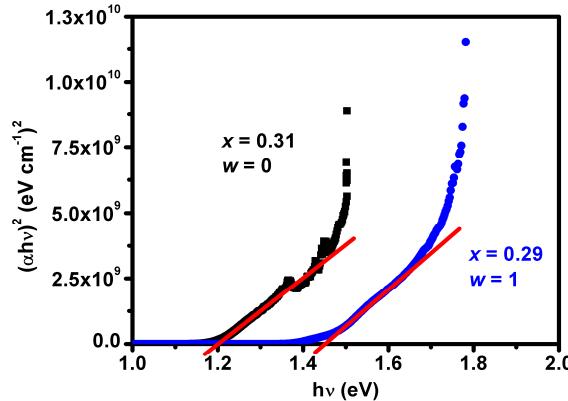


Figure 2.  $(\alpha h\nu)^2$  vs.  $h\nu$  for 2 films with  $x = 0.31$ : black)  $\text{Cu}(\text{In},\text{Ga})\text{Se}_2$  control ( $w = 0$ ), blue)  $(\text{Ag},\text{Cu})(\text{In},\text{Ga})\text{Se}_2$  with  $w = 1$ . Red lines show the extended fitline to determine  $E_g$ .

Table I. Bandgaps determined from T and R measurements for samples from Figure 2 with  $x = 0.31$ . Included are the statistical absolute error ( $\Delta E_g$ ) and coefficient of determination ( $r^2$ ) of the fits.

$w$	$E_g$ (eV)	$\Delta E_g$ (eV)	$r^2$	Number of data points for fit
0	1.19	0.01	0.9976	100
1	1.45	0.01	0.9992	75

Table II – Bandgaps estimated from T and R measurements for  $(\text{Ag},\text{Cu})(\text{In},\text{Ga})\text{Se}_2$  thin films for  $x$  groups.

$x$	$w$	$E_g$ (eV)	$\Delta E_g$ (eV)
0.31	0	1.19	0.01
	0.16	1.20	0.01
	0.28	1.22	0.01
	0.47	1.26	0.01
	0.75	1.34	0.01
	1	1.45	0.01
0.52	0	1.32	0.01
	0.27	1.35	0.01
	0.46	1.39	0.02
	0.76	1.47	0.02
	1	1.56	0.02
0.82	0[11]	1.52	0.01
	0.16	1.55	0.03
	0.27	1.58	0.02
	0.50	1.61	0.03
	0.76	1.63	0.04
	1	1.76	0.03

The bandgaps from Table II are shown in Figure 3. For each set of different  $x$ , the optical bowing parameter ( $b$ ) was determined using Equation 2:[12]

$$E_g(A, B) = xE_g(A) + (1-x)E_g(B) - x(1-x)b \quad (2)$$

where  $x$  is the composition ratio for Ag,  $E_g(A, B)$  is the bandgap at that Ag composition, and  $E_g(A)$  and  $E_g(B)$  are the highest and lowest values of  $E_g$  in the group, respectively. The values of  $b$  are listed in Table III.

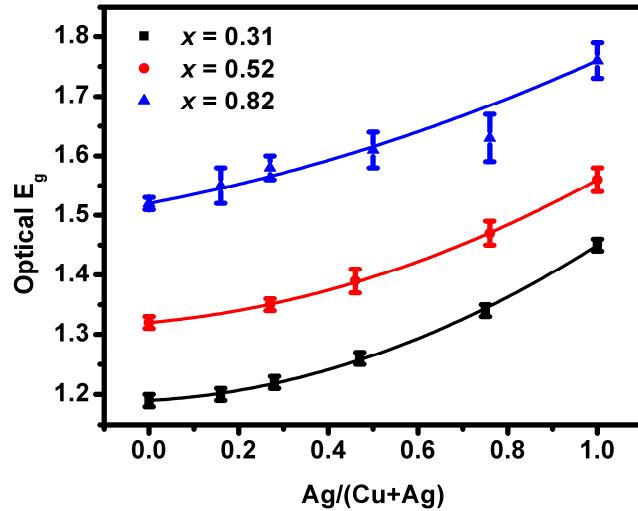


Figure 3. Optical bowing parameter fitting plots by  $x$  groups.

Table III – Optical bowing parameters determined from Equation 2 fitting, for  $x$  groups. The error for  $b$  ( $\Delta b$ ) is the standard error ( $\sigma / \sqrt{N}$ ).

$x$	$b$	$\Delta b$
0.31	0.20	0.02
0.52	0.17	0.01
0.82	0.10	0.05

The bandgaps from the above films, along with the results from a few additional samples are replotted in Figure 4 with fixed  $w$  and varying  $x$ . The curves show fits with Equation 2, where in this case the  $x$  parameter

corresponds to the Ga composition ratio, and the resulting bowing parameters are listed in Table IV. In Figure 4 literature values were used for the  $x = 0$  case [13] and the  $w = 0$  case [11].

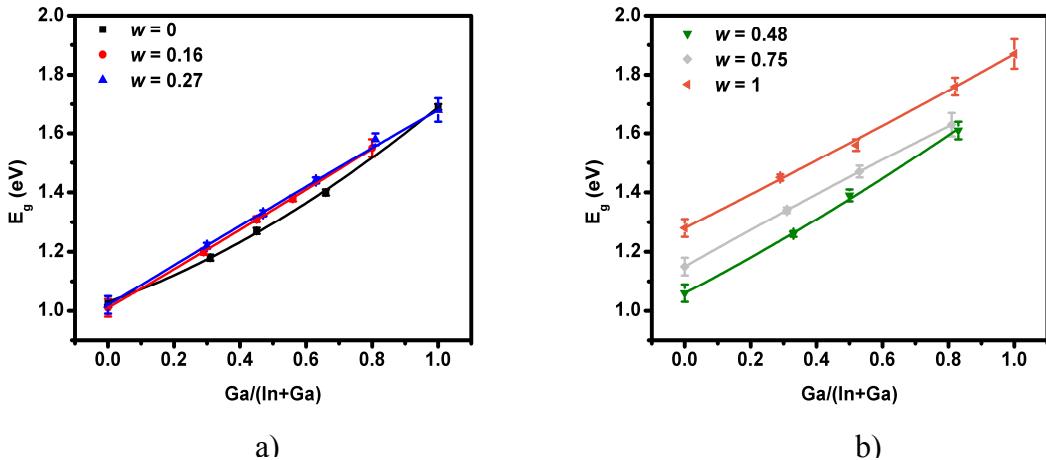


Figure 4. Bandgaps for sets of samples with fixed  $w$  and varying  $x$  and corresponding fits to determine  $b$ . a)  $w = 0-0.27$  and b)  $w = 0.48-1$ .

Table IV – Optical bowing parameters with fixed  $w$  and varying  $x$ . Error for  $b$  ( $\Delta b$ ) is standard error ( $\sigma / \sqrt{N}$ ).

$w$	$b$	$\Delta b$
0	0.26	0.01
0.16	0.03	0.02
0.27	-0.01	0.01
0.48	0.11	0.05
0.75	-0.04	0.01
1	0.03	0.02

Figure 4 shows a similar result to Figure 3 in that the bandgap does not increase much with slight additions of Ag to Cu(In,Ga)Se<sub>2</sub>. Only at  $w > 0.48$  does the bandgap effectively increase. This is readily visible in Figure 4 (a) in that the  $w = 0.16$  and  $0.27$  groups overlay each other and show only a slight increase in bandgap compared to the  $w = 0$  control.

Normalized QE curves of devices using (Ag,Cu)(In,Ga)Se<sub>2</sub> with  $x = 0.31$  are shown in Figure 5. The bandgaps of the (Ag,Cu)(In,Ga)Se<sub>2</sub> samples were determined by the relative shift in the long wavelength QE

edge from the Cu(In,Ga)Se<sub>2</sub> sample at the horizontal dashed line. This line is positioned to give the value of  $E_g = 1.19$  eV for the Cu(In,Ga)Se<sub>2</sub> sample, as determined from the optical analysis above and in agreement with the literature result for that composition determined using spectroscopic ellipsometry [11]. This analysis assumes there are no significant differences in current collection in the devices which would change the slope of the QE edges. The  $E_g$  results are compared to the optical results with  $x = 0.31$  in Table V and the two methods yield similar results. Small differences with  $w = 0.75$  and  $1$  may be an indication of greater uncertainty in the optical analysis.

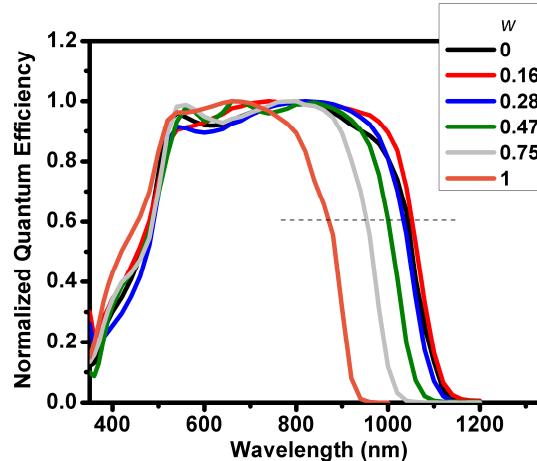


Figure 5. Normalized quantum efficiency curves for  $x = 0.31$  and varying  $w$ . The black dashed horizontal line shows where the relative shift analysis to determine  $E_g$  was performed.

Table V. Bandgaps estimated from T and R measurements and QE results for samples with  $x = 0.31$ .

$w$	Optical $E_g$ (eV)	Optical $\Delta E_g$ (eV)	QE $E_g$ (eV)
0	1.19	0.01	1.19
0.16	1.20	0.01	1.18
0.28	1.22	0.01	1.20
0.47	1.26	0.01	1.24
0.75	1.34	0.01	1.30
1	1.45	0.01	1.42

The QE curves were compared for devices with  $x = 0.52$  and  $0.82$ , but are not shown. The QE curves for those  $x$  groups had different long-wavelength tail slopes, attributed to differences in current collection [14], which prohibited determination of  $E_g$  from the QE.

## CONCLUSIONS

(Ag,Cu)(In,Ga)Se<sub>2</sub> films have been grown by elemental co-evaporation and their optical properties and bandgaps characterized by UV/Vis/NIR spectrophotometry. Low sub-band absorption of the (Ag,Cu)(In,Ga)Se<sub>2</sub> samples suggest that the samples had lower densities of defects, compared to Cu(In,Ga)Se<sub>2</sub>. Bandgaps were determined by analysis of T and R measurements and the optical bowing parameters were determined for alloying with Ag/(Cu+Ag) or Ga/(In+Ga). For  $Ga/(In+Ga) = 0.31$ , the optical  $E_g$  results were compared to  $E_g$  determined by the shift in the QE edge of solar cell devices from the same deposition and gave good agreement. With higher Ga contents, the QE edges had different slopes so quantitative analysis of the shifts to determine  $E_g$  could not be completed.

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